12/08/1997 IPERPLES 00000073 08636069 he documents referred to as 02 FC: 103 closed therein are being deposited with the United States Postal Service as first class main in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, DC 20231 on: November 25, 1997.

(Signature of person mailing papers)

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N THE UNITED STATES PATENT AND TRADEMARK OFFICE

#5/a mR 12/24/97

In re Application of:

Sandhu, Gurtej

Serial number:

08/636,069

Filed:

4/22/96

Group Art Unit:

1104

Examiner:

Matthew Whipple

Title:

Method To Reduce Fixed Charge In

CVD Ozone Deposited Films

RESPONSE TO OFFICE ACTION

Mailed: 08/18/97

<u>AMENDMENT A</u>

COMMISSIONER OF PATENTS AND TRADEMARKS Box Fee Amendment Commissioner of Patents and Trademarks Washington, DC 20231

Dear Sir:

In response to the Office Action mailed August 18, 1997, please enter the following amendments and remarks of record.

IN THE SPECIFICATION

On page 6, line 3, after "volume." please insert the sentence -- The term substrate refers to one or more semiconductor layers or structures which includes active or operable portions of semiconductor devices. --

On page 6, line 6, after "reaction" please insert -- volume of gas, above the --.

On page 8, line 3, after the word "turn" please delete the word "will".

RESPONSE TO OFFICE ACTION SN 08/636,069

Page 1 of 10 Amendment A